

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	236	438/481.ccls.	USPAT	OR	OFF	2005/04/08 15:35
L2	214	438/492.ccls.	USPAT	OR	OFF	2005/04/08 15:35
L3	104	438/503.ccls.	USPAT	OR	OFF	2005/04/08 15:35
L4	164	438/507.ccls.	USPAT	OR	OFF	2005/04/08 15:35
L5	900	438/301.ccls.	USPAT	OR	OFF	2005/04/08 15:35
L6	334	438/514.ccls.	USPAT	OR	OFF	2005/04/08 15:35
L7	75	438/519.ccls.	USPAT	OR	OFF	2005/04/08 15:35
L8	63	438/523.ccls.	USPAT	OR	OFF	2005/04/08 15:35
L9	329	438/527.ccls.	USPAT	OR	OFF	2005/04/08 15:36
L10	286	438/931.ccls.	USPAT	OR	OFF	2005/04/08 15:36
L11	14	tan-chung\$.in. lee-hyeok\$.in. liu-jinping\$.in. indajang-bangun\$. in. chor-eng\$.in. ong-shiang\$.in.	USPAT	OR	OFF	2005/04/08 15:36
L12	6	tan-chung\$.in. lee-hyeok\$.in. liu-jinping\$.in. indajang-bangun\$. in. chor-eng\$.in. ong-shiang\$.in.	US-PGPUB	OR	OFF	2005/04/08 15:36
L13	4	tan-chung\$.in. lee-hyeok\$.in. liu-jinping\$.in. indajang-bangun\$. in. chor-eng\$.in. ong-shiang\$.in.	EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/04/08 15:36
L14	11830	(carb\$6 "sic") and (epitax\$6)	USPAT	OR	ON	2005/04/08 15:42
L15	10466	14 and (substrate wafer bulk)	USPAT	OR	ON	2005/04/08 15:38
L16	7011	15 and (gate electrode mosfet mos)	USPAT	OR	ON	2005/04/08 15:39
L17	3074	16 and implant\$6	USPAT	OR	ON	2005/04/08 15:43
L18	2633	17 and (source drain halo ldd)	USPAT	OR	ON	2005/04/08 15:42
L19	315	18 and (halo ldd)	USPAT	OR	ON	2005/04/08 15:41
L20	2630	17 and (source drain)	USPAT	OR	ON	2005/04/08 15:41
L21	1528	20 and ((source drain) same implant\$6)	USPAT	OR	ON	2005/04/08 15:42
L22	5865	(carb\$6 "sic") and (epitax\$6)	US-PGPUB	OR	ON	2005/04/08 15:43
L23	2193	22 and implant\$6	US-PGPUB	OR	ON	2005/04/08 15:42
L24	1767	23 and (source drain halo ldd)	US-PGPUB	OR	ON	2005/04/08 15:43
L25	2830	(carb\$6 "sic") and (epitax\$6)	EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/08 15:43
L26	215	25 and implant\$6	EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/08 15:43
L27	437	25 and (source drain halo ldd)	EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/08 15:43